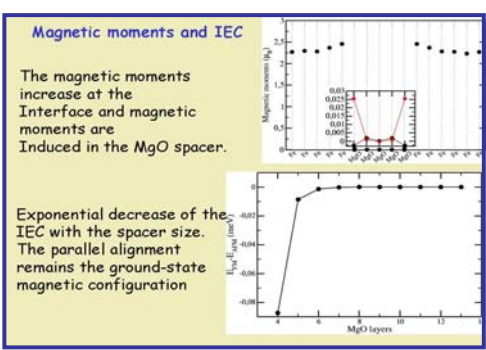
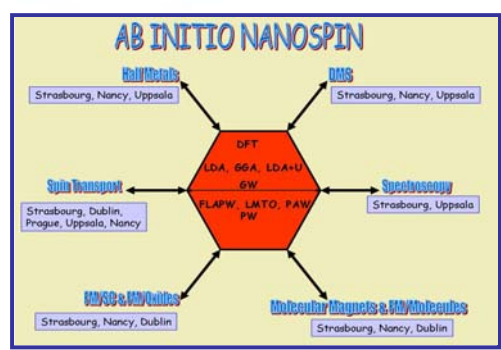


Ab initio Simulation of Transport in Nanospintronics

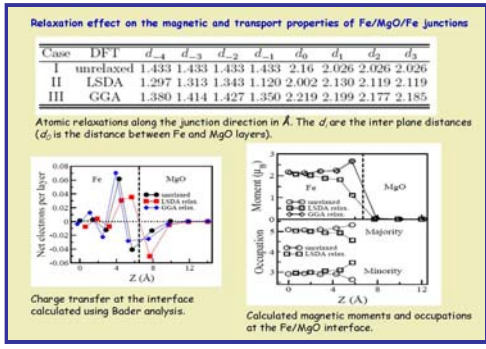
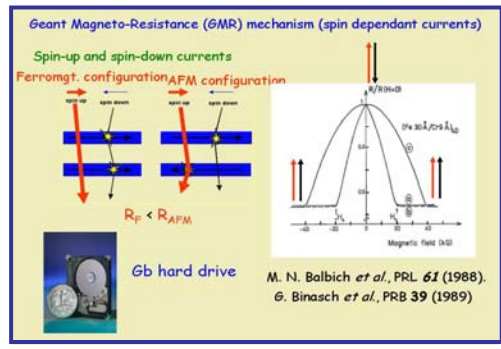
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- ### Conclusions:
- IEC favor parallel alignment of the magnetization at the interfaces of Fe/MgO/Fe
 - The calculated TMR values are higher than experiment -> Atomic relaxations have a strong effect on the TMR
 - Adding vanadium at the Fe interface acts as an extra barrier reducing the TMR, and its different magnetic states can change it considerably
 - The double barriers Fe/V/Fe/MgO/Fe offers many possibilities to change the TMR as a function of the different magnetic states.
- ### Perspectives:
- Extend this study to molecular spacers
 - Use half-metals (like SFMO) or DMS as leads
 - Transport with finite bias (non-equilibrium Green's function formalism)



Molecular Electronics

